

Resource Summary Report

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Agilent: 7700s ICP-MS

RRID:SCR_019443

Type: Tool

Proper Citation

Agilent: 7700s ICP-MS (RRID:SCR_019443)

Resource Information

URL: <https://www.agilent.com/en/products/icp-ms/icp-ms-systems/7700s-icp-ms>

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Description: Discontinued. Has interference removal utilizing ORS3 cell that removes spectral interferences using He mode, reaction mode using hydrogen cell gas and 3rd cell gas line for other reaction gases, cool plasma capability also delivers ionized elements in high-purity materials in matrices, built-in tuning and method templates for common semiconductor applications, including collision and reaction mode and cool plasma, lower heat output and reduced exhaust vent flow with cooling air flow management system, uses ICP-MS MassHunter software platform, and compact benchtop design.

Resource Type: instrument resource

Keywords: Agilent, ICP-MS, Instrument Equipment, USEDit,

Availability: Commercially available

Specification URL: https://raw.githubusercontent.com/SciCrunch/RRID-Instruments/refs/heads/main/PDF/SCR_019443.pdf

Resource Name: Agilent: 7700s ICP-MS

Resource ID: SCR_019443

Alternate IDs: Model_Number_7700s

Record Creation Time: 20220129T080345+0000

Record Last Update: 20260808T190133+0000

Ratings and Alerts

No rating or validation information has been found for Agilent: 7700s ICP-MS.

No alerts have been found for Agilent: 7700s ICP-MS.

Data and Source Information

Source: [SciCrunch Registry](#)

Usage and Citation Metrics

We have not found any literature mentions for this resource.